



Patent

in re application of:
Trung T. Doan

Serial No.: 09/133,989

Filed: August 14, 1998

For: CHEMICAL DISPENSING SYSTEM
FOR SEMICONDUCTOR WAFER
PROCESSING

§ Group Art Unit: 1734
§
§ Examiner: L. Edwards
§
§ Atty. Docket: 93-0421.03
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Certificate of Mailing (37 C.F.R. § 1.8)

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail, postage prepaid, in an envelope addressed to: Commissioner for Patents, Washington, D.C. 20231, on the date below:

12/2/02
Date

Susan Jerome
Signature

PETITION FOR EXTENSION OF TIME UNDER 37 C.F.R. § 1.136(a)

Commissioner for Patents
Washington, D.C. 20231

Dear Sir:

Applicant hereby petitions to extend the period for response to the Office Action mailed August 1, 2002 for one (1) month(s), from November 1, 2002 to December 1, 2002.

☒ Because December 1, 2002 falls on a Sunday in the District of Columbia, the period for response extends to December 2, 2002.

Accordingly, the requisite fee is \$ 110. The Commissioner is requested to charge this fee, and any additional fee, which may be required to Micron Technology, Inc. Deposit Account 13-3092, Order No. 93-0421.03. A duplicate copy of this petition is enclosed.

Respectfully submitted,

Charles Brantley

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Date: 12/2/02

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